

**Amendments to the Claims:**

This listing of claims will replace the listing of claims as pending in the present application:

**Listing of Claims:**

Claim 1 (original): A  $\text{SrRuO}_3$  conductive oxide sintered body characterized in that the relative density is 93% or more.

Claim 2 (original): A conductive oxide sintered body according to claim 1, characterized in that the resistivity is  $500 \mu \Omega\text{cm}$  or less.

Claim 3 (original): A conductive oxide sintered body according to claim 1, characterized in that the resistivity is  $300 \mu \Omega\text{cm}$  or less.

Claims 4-5 (canceled).

Claim 6 (original): A sputtering target formed from a  $\text{SrRuO}_3$  conductive oxide sintered body characterized in that the relative density is 93% or more.

Claim 7 (original): A sputtering target formed from a conductive oxide sintered body according to claim 6, characterized in that the resistivity is  $500 \mu \Omega\text{cm}$  or less.

Claim 8 (original): A sputtering target formed from a conductive oxide sintered body according to claim 6, characterized in that the resistivity is  $300 \mu \Omega\text{cm}$  or less.

Claims 9-10 (canceled).

Claim 11 (original): A manufacturing method of a  $\text{SrRuO}_3$  conductive oxide sintered body or a sputtering target formed from said sintered body, characterized in that 0.3mol to 1.2mol of  $\text{Bi}_2\text{O}_3$  is added as a sintering auxiliary upon manufacturing the  $\text{SrRuO}_3$  conductive oxide sintered body.

Claims 12-14 (canceled).